

**Improved performance of UV-blue dual-band Bi₂O₃/TiO₂
photodetector and application of visible light communication with
UV light encryption**

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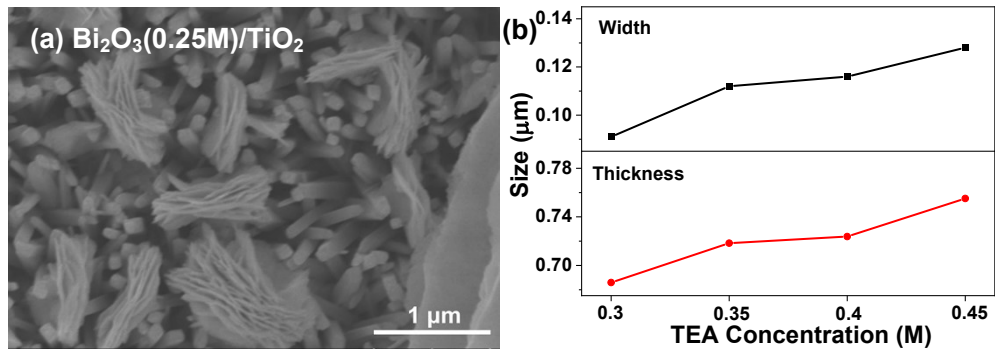


Fig.S1 (a) SEM image of $\text{Bi}_2\text{O}_3(0.25\text{M})/\text{TiO}_2$ and (b) lateral dimension and thickness of individual $\text{Bi}_2\text{O}_3/\text{TiO}_2$ nanosheets with different TEA concentrations.

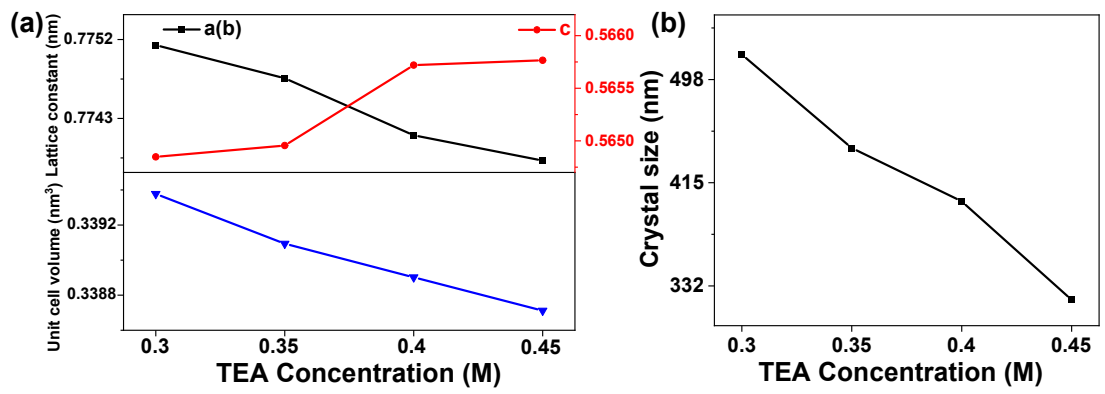


Fig.S2 (a) Lattice constants and crystal volume, and (b) crystal size of Bi₂O₃/TiO₂ with different TEA concentrations.

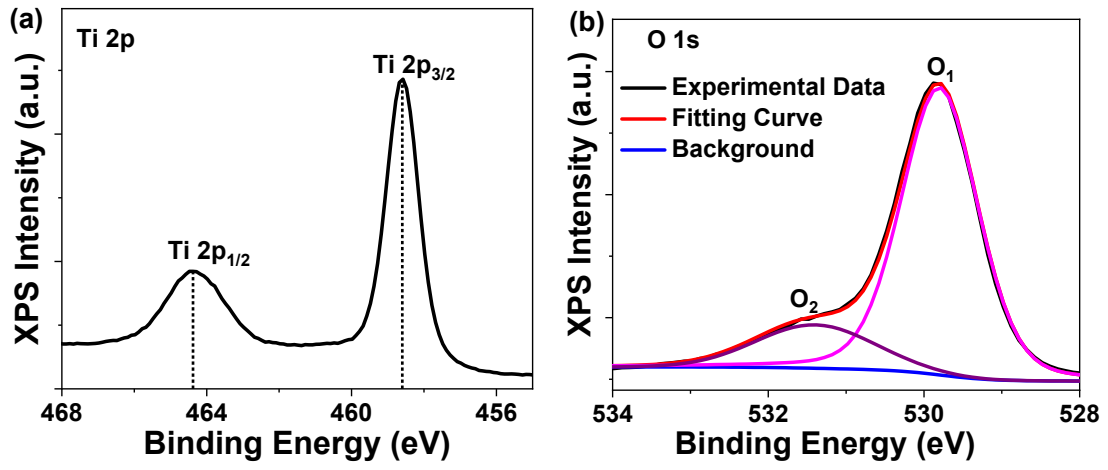


Fig.S3 (a) Ti 2p and (b) O 1s XPS spectra of TiO₂ NRs.

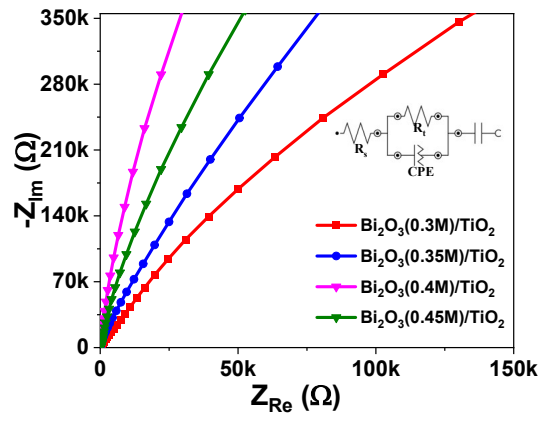


Fig.S4 EIS curves of Bi₂O₃/TiO₂ with different TEA concentrations.

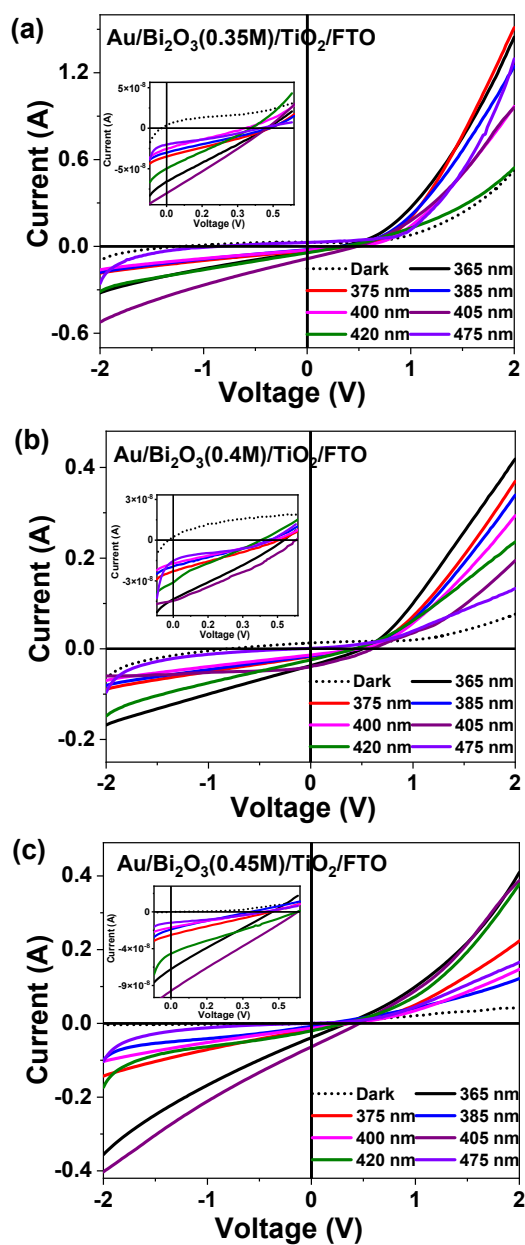


Fig.S5 I-V curves of (a) Bi₂O₃(0.35M)/TiO₂, (b) Bi₂O₃(0.4M)/TiO₂ and (c) Bi₂O₃(0.45M)/TiO₂ devices.

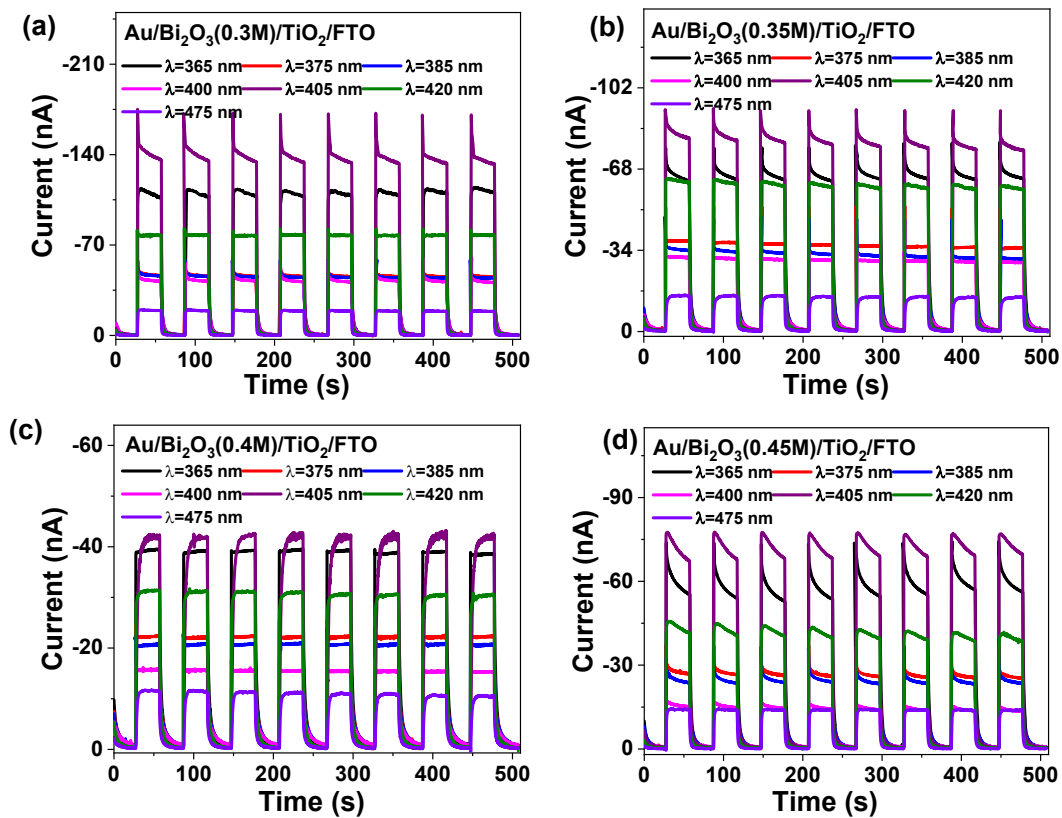


Fig.S6 I-t curves of (a) Bi₂O₃(0.3M)/TiO₂, (b) Bi₂O₃(0.35M)/TiO₂, (c) Bi₂O₃(0.4M)/TiO₂ and (d) Bi₂O₃(0.45M)/TiO₂ devices.

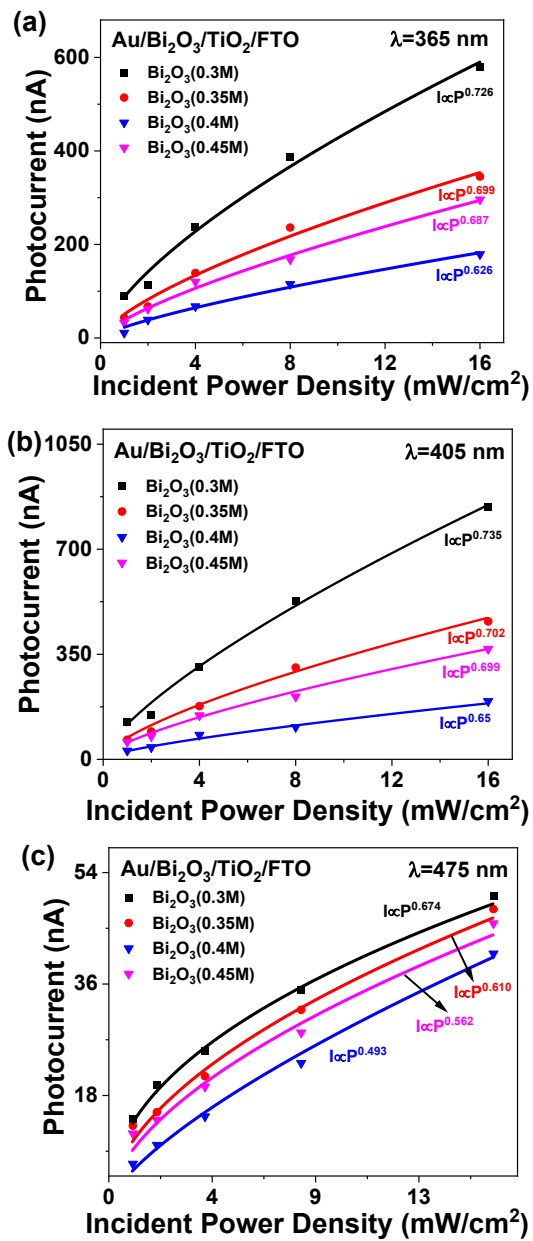


Fig.S7 I_{ph} of Au/Bi₂O₃/TiO₂/FTO devices under (a) 365 nm UV light, (b) 405 nm and (c) 475 nm illuminations with different incident powers.

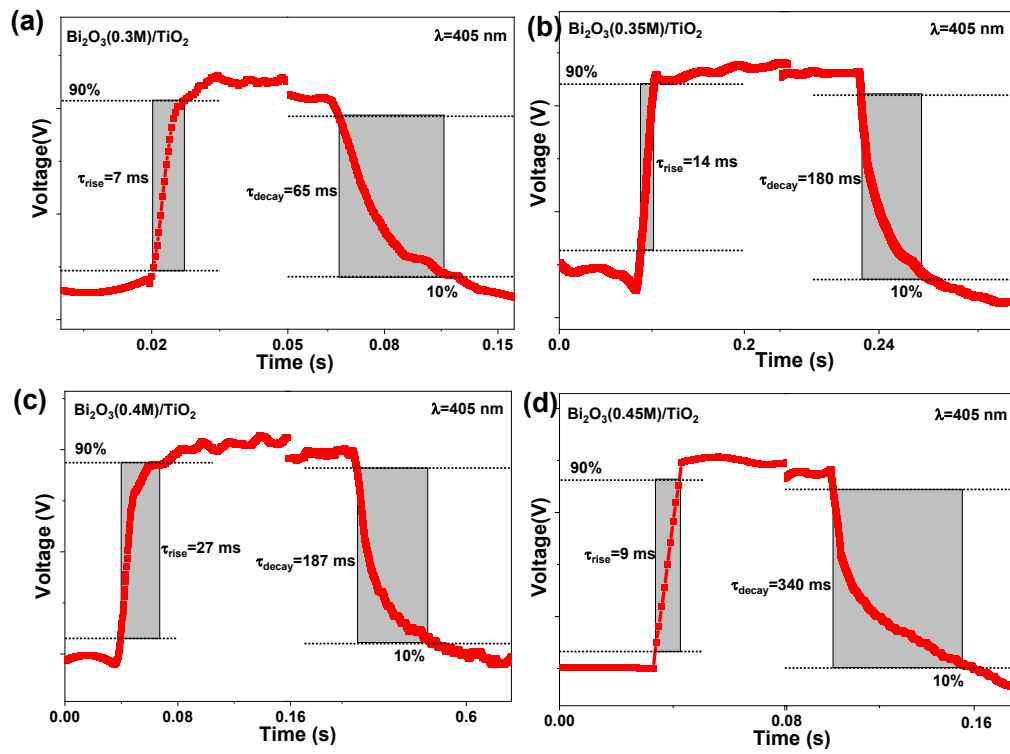


Fig.S8 τ_{rise} and τ_{decay} of (a) $\text{Bi}_2\text{O}_3(0.3\text{M})/\text{TiO}_2$, (b) $\text{Bi}_2\text{O}_3(0.35\text{M})/\text{TiO}_2$, (c) $\text{Bi}_2\text{O}_3(0.4\text{M})/\text{TiO}_2$ and (d) $\text{Bi}_2\text{O}_3(0.45\text{M})/\text{TiO}_2$ devices at 405 nm light illumination.

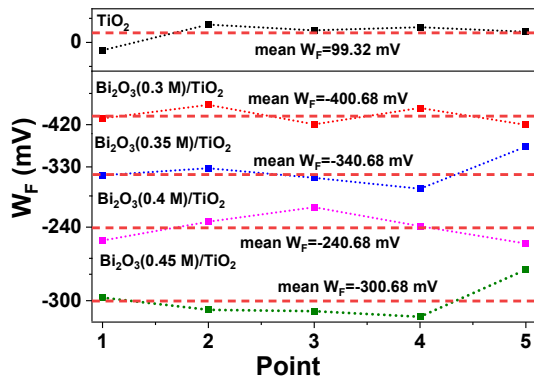


Fig.S9 Fermi energy level curves obtained from Kelvin probes of TiO_2 and $\text{Bi}_2\text{O}_3/\text{TiO}_2$ with different TEA concentrations.

Table.S1 TiO_2 and Bi_2O_3 films energy band structure related parameters

Samples	TiO_2	$\text{Bi}_2\text{O}_3(0.3\text{M})$	$\text{Bi}_2\text{O}_3(0.35\text{M})$	$\text{Bi}_2\text{O}_3(0.4\text{M})$	$\text{Bi}_2\text{O}_3(0.45\text{M})$
E_F (eV)	-4.46	-4.96	-4.90	-4.80	-4.86
E_g (eV)	3.00	2.42	2.42	2.42	2.42
E_c (eV)	-4.06	-3.36	-3.30	-3.20	-3.26
E_v (eV)	-7.06	-5.73	-5.67	-5.57	-5.63

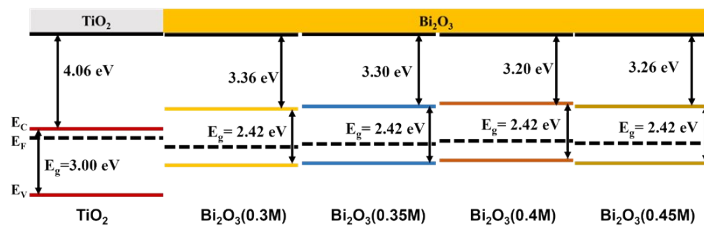


Fig.S10 Band diagrams before contact of $\text{Bi}_2\text{O}_3/\text{TiO}_2$ heterojunctions.